CLAIMS

- 1 1. A vacuum pumping system comprising a pump having an inlet for receiving
- from a vacuum chamber at least a first gas to be pumped; means for supplying a
- second, purge gas to be pumped with the first gas; the pump having an outlet for
- 4 exhausting a gas stream comprising the first gas and the purge gas; and gas
- separating means for receiving the gas stream and recovering the purge gas from
- the stream, the supply means being arranged to receive from the gas separating
- 7 means the recovered purge gas.
- 1 2. The system as claimed in claim 1, wherein the supply means is arranged to
- 2 supply the purge gas directly to the pump.
- 1 3. The system as claimed in claim 1, wherein the supply means is arranged to
- 2 supply the purge gas to the vacuum chamber.
- 1 4. The system as claimed in claim 1, comprising a second pump having an
- 2 inlet for receiving the gas stream from the first-mentioned pump and an outlet for
- 3 exhausting the gas stream to the gas separating means.
- 1 5. The system as claimed in claim 1, comprising a second pump having an
- 2 inlet for receiving the recovered purge gas and an outlet for exhausting the
- 3 recovered purge gas to the conveying means.
- 1 6. The system as claimed in claim 5, comprising means for purifying the gas
- 2 exhaust from the second pump.
- 7. The system as claimed in claim 1, comprising first gas recirculating means
- for recirculating first gas from the separating means to the vacuum chamber.

- 1 8. The system as claimed in claim 7, wherein the recirculating means
- 2 comprises means for purifying the received first gas.
- 1 9. The system as claimed in claim 8, wherein the recirculating means
- 2 comprises means for pressurising the received first gas.
- 1 10. The system as claimed in claim 9, wherein the separating means comprises
- 2 cryogenic separating means for separating cryogenically the first gas from the gas
- 3 stream to recover both the first and second gases.
- 1 11. The system as claimed in claim 10, wherein the cryogenic separating
- 2 means is arranged to condense the first gas without condensing the second gas.
- 1 12. The system as claimed in claim 1, wherein the first pump comprises a
- 2 turbo-molecular pump.
- 1 13. The system as claimed in claim 1, wherein the first gas comprises a low
- 2 thermal conductivity gas.
- 1 14. The system as claimed in claim 13 wherein said low thermal conductivity
- 2 gas is selected from the group consisting of xenon and argon.
- 1 15. The system as claimed in claim 1, wherein the purge gas is lighter than the
- 2 first gas.
- 1 16. The system as claimed in claim 15, wherein the purge gas comprises one of
- 2 helium and nitrogen.
- 1 17. A vacuum pumping system, comprising first gas supply means for supplying
- a first gas to a vacuum chamber; a pump arranged to receive at least the first gas
- from the chamber; second gas supply means for supplying a second gas for

- 4 pumping with the first gas; and gas separating means for receiving a gas stream
- output from the pump, recovering the first and second gases from the gas stream,
- 6 outputting the recovered first gas to the first gas supply means for recirculation
- through at least the chamber and outputting the recovered second gas to the
- second gas supply means for recirculation through at least the pump.
- 1 18. An extreme ultra violet lithography apparatus comprising a vacuum
- 2 pumping system as claimed in claim 1.
- 1 19. A method of vacuum pumping, comprising receiving at a pump at least a
- 2 first gas from a vacuum chamber, and a second, purge gas for pumping with the
- first gas; exhausting from the pump a gas stream comprising the first and second
- 4 gases; recovering the second gas from the stream and recirculating the second
- 5 gas through at least the pump.
- 1 20. The method as claimed in claim 19, wherein the second gas is recirculated
- through both the vacuum chamber and the pump.
- 1 21. The method as claimed in claim 19, wherein the pressure of the gas stream
- 2 exhausted from the pump is increased prior to the recovery of the second gas
- 3 therefrom.
- 1 22. The method as claimed in claim 19, wherein the pressurised gas stream is
- 2 purified prior to the recovery of the second gas stream therefrom.
- 1 23. The method as claimed in claim 19, wherein the pressure of the recovered
- 2 second gas is increased prior to its recirculation.
- 1 24. The method as claimed in claim 23, wherein the pressurised, recovered
- 2 second gas is purified prior to its recirculation.

- 1 25. The method as claimed in claim 19, wherein the first gas is recovered from
- 2 gas stream and recirculated to the vacuum chamber.
- 1 26. The method as claimed in claim 25, wherein the recovered first gas is
- 2 purified prior to its return to the vacuum chamber.
- 1 27. The method as claimed in claim 26, wherein the recovered first gas is
- 2 pressurised prior to its return to the vacuum chamber.
- 1 28. The method as claimed in claim 19, wherein the first gas is cryogenically
- 2 separated from the gas stream to recover the first and second gases.
- 1 29. The method as claimed in claim 28, wherein the first gas is condensed
- without condensing the second gas to separate the first and second gases.
- 1 30. The method as claimed in claim 19, wherein the first gas comprises a low
- 2 thermal conductivity gas.
- 1 31. The method as claimed in claim 30 wherein said low thermal conductivity
- 2 gas is selected from the group consisting of xenon and argon.
- 1 32. The method as claimed in claim 19, wherein the second gas is lighter than
- 2 the first gas.
- 1 33. The method as claimed in claim 19, wherein the second gas comprises one
- 2 of helium and nitrogen.